

IFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:	Huey-Chiang Liou et al.	§	Group Art Unit:	2823
		§		
Serial No.:	10/695,103	§		
		§	Examiner:	Trung Q. Dang
Filed:	October 28, 2003	§		
		§		
For:	Langmuir-Blodgett Chemically	§	Atty. Dkt. No.:	ITL.1054US
	Amplified Photoresist	§		(P17790)
		§		
Customer	21906	§	Confirmation No.:	4735
No.:				

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REPLY TO PAPER NO. 080904

Dear Sir:


In response to the Office Action of August 20, 2003, please consider the following:

CLAIM AMENDMENTS, which begin on page 2 of this paper; and

REMARKS, which begin on page 4 of this paper.

Date of Deposit: October 26, 2004

I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as **first class mail** with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.


Ellen Peacock